

CORPRATE PRESENTATION

September 2025



“World-leading supplier
of lithography solutions”



WHAT WE DO

We enable the development of nanotechnology

Obducat's business concept is to develop and supply nanolithography processing solutions for production and replication of advanced micro- and nanostructures for mass-production as well as for R&D purposes.

Since the founding of Obducat in 1989, the company has accumulated more than 35-years experience in developing and supplying innovative lithography solutions.



WHAT WE OFFER

A competitive edge, know-how
and customized solutions within:

- Nanoimprint Lithography, NIL
- Resist processing
- Wet processing
- Foundry services

We provide customers with a competitive edge through delivery of cost-effective lithography solutions. Our user-friendly turn-key systems are widely known for their high quality and low Cost-of-Ownership.



60

Highly skilled
and dedicated
specialists

700+

Customer
installations
worldwide

Our facilities
encompass
2000 m²

163

Patent applications
of which more
than 154 are
granted patents

Obducat is
listed on Nordic
Growth Market
Stock Exchange
in Sweden

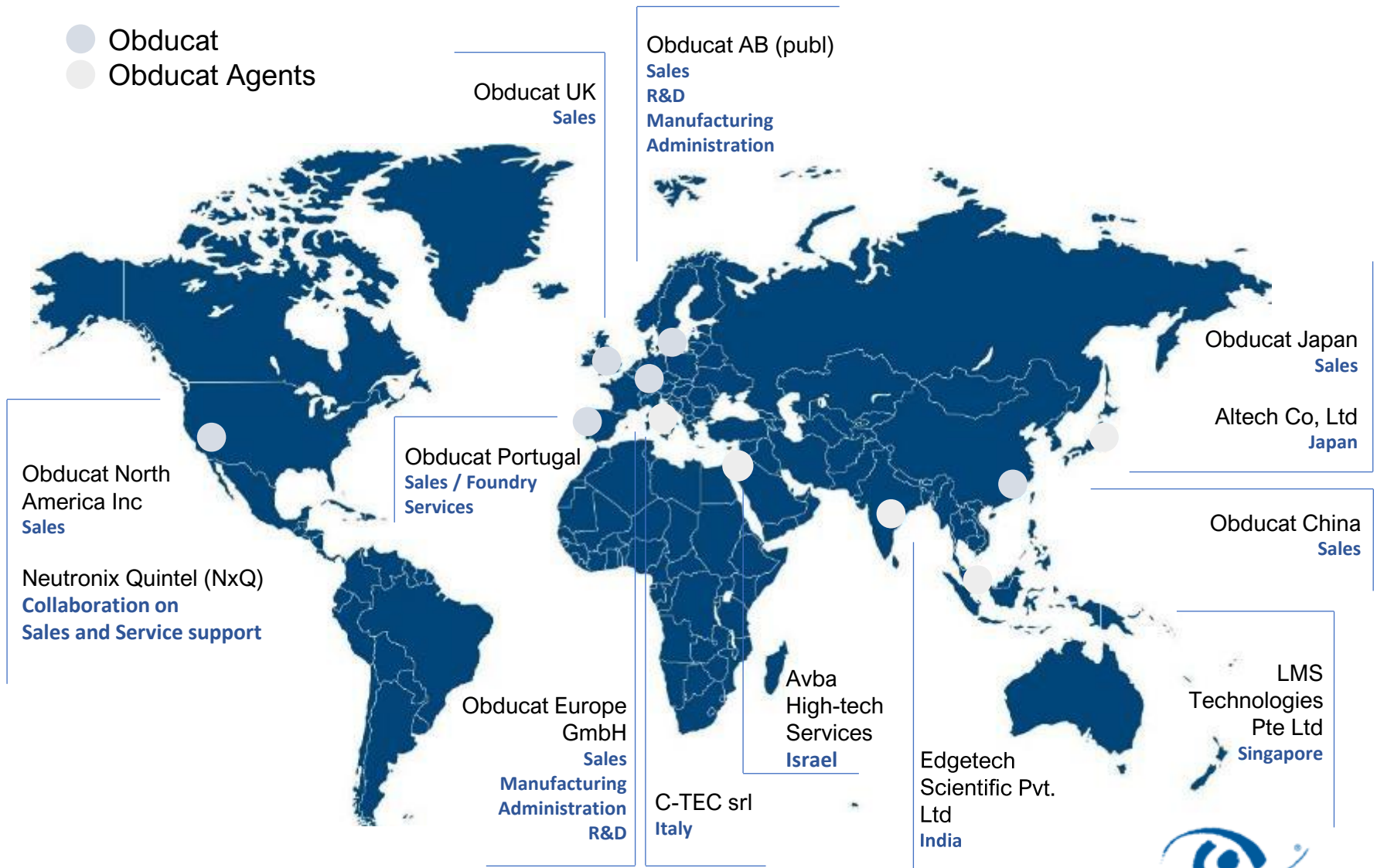
www.ngm.se

150 m² Class
10/100
cleanroom for
contract
manufacturing

"World-leading supplier
of lithography solutions"

OBDUCAT WORLDWIDE

- Obducat
- Obducat Agents



"World-leading supplier
of lithography solutions"

PRODUCTS & SERVICES

Nanoimprint Lithography Tools



Eitre®
semi-automated
tools for substrate
sizes up to 200
mm.



Eitre® Large Substrates
semi-automated tool for
substrate sizes up to 500
mm.



Sindre® Integra
fully automated tool
for substrate sizes up
to 300 mm.



Sindre® Litho Track
fully integrated Nanoimprint
Lithography tool.

"World-leading supplier
of lithography solutions"

PRODUCTS & SERVICES

Resist Processing Tools



Quickstep

Semi-automated coater and developer for substrate sizes 200 and 300 mm and for large substrates up to 1500 mm.



Microcluster

Fully automated coater and developer for substrate sizes 200 and 300 mm.



Microcluster Track

Fully automated coater and developer for substrate size 200, 300 and up to 1500 mm.

PRODUCTS & SERVICES

Wet Processing Tools



Quickstep Wet

Semi-automated wet tools for cleaning, lift-off, etching or developing. Ability to process substrate sizes 200 and 300 mm and large substrates up to 1500 mm.



Microcluster Wet

Fully automated wet tools for cleaning, lift-off, etching or developing. Ability to process substrate sizes 200 and 300 mm and large substrates up to 1500 mm.



Microcluster Wet Track

Fully automated wet processing track tools for cleaning, lift-off, etching or developing. Ability to process substrate sizes 200 and 300 mm and large substrates up to 1500 mm.



"World-leading supplier
of lithography solutions"

FOUNDRY SERVICES

Based on Obducat's exceptional internal nanolithography process know-how

Comprehensive Processing

All processes available up to 200 mm substrate size

Full Capability Range

From substrate preparation and lithography processes to advanced pattern transfer

Scalable Production

Supporting prototyping to high-volume manufacturing

"World-leading supplier
of lithography solutions"

OBDUCAT MARKET FOCUS APPLICATIONS



Optical &
Photonic
Devices



LEDs &
Display



MEMS &
Sensor
Devices



Bio &
Medical
Devices



High Power &
High Frequency
Components

CONTACT US

www.obducat.com

Obducat AB (publ)

Scheelevägen 2
22363 Lund
Sweden

Obducat Europe GmbH

Robert-Gerwig-Str. 9
78315 Radolfzell
Germany

Obducat USA Inc.

851 Burlway Rd, #605
Burlingame, Ca 94010
USA

Obducat Asia Ltd

Suite 1201, Tower 2,
The Gateway
25 Canton Rd.,
Tsimshatsui, Kowloon
Hong Kong

THANK YOU FOR YOUR ATTENTION!

